U.S. PATENT ATTY. DOCKET NO. APPLICATION NO. 1509-467 INFORMATION DISCLOSURE 10/698,028 CITATION IN AN APPLICANT APPLICATION David SIKHARULIDZE FILING DATE **GROUP** (PTO-1449) 1772 October 31, 2003 U.S. PATENT DOCUMENTS **EXAMINER'S** FILING **SUBCLASS** INITIALS PATENT NO. DATE NAME **CLASS** DATE 4.305,807 12-15-1981 204 299 R 3-13-1980 Somlyody SH FOREIGN PATENT DOCUMENTS ... 5.2 **EXAMINER'S** Translation PATENT NO. DATE COUNTRY CLASS **SUBCLASS** Yes INITIALS GB 2 324 620 10-28-1998 UK OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.) Thurston et al., "Mechanically Bistable Liquid-Crystal Display Structures," IEEE Transactions on Electron Devices, Vol. ED-27, No. 11, November 1980, pp. 2069-2080 SH Dozov et al., "Fast bistable nematic display using monostable surface switching," Appl. Phys. Lett. 70 (9), March 3, 1997, pp. 1179-1181 SH Bartolino et al., "Polarity sensitive electrooptical response in a nematic liquid crystal-polymer mixture," Journal of Applied Physics, Vol. 85, No. 5, March 1, 1999, pp. 2870-2874 SH Eidenschink et al., "Static Scattering in Filled Nematic: New Liquid Crystal Display Technique," Electronics Letters, Vol. 27, No. 13, June 20, 1991, pp. 1195-1196 SH Glushchenko et al., "Memory effect in filled nematic liquid crystals," Liquid Crystals, Vol. 23, No. 2 (1997), pp. 241-246 SH Kawasumi et al., "Nematic liquid crystal/clay mineral composites," Materials Science and Engineering C 6 (1998), pp. 135-143 SH Kreuzer et al., "New liquid crystal display with bistability and selective erasure using scattering in filled nematics," Appl. Phys. Lett. 62 (15), April 12, 1993, pp. 1712-1714 SH Lee et al., "Dynamic behavior of silica particles in liquid crystals under an ac applied voltage," Proceedings of 13th International Conference on Dielectric Liquids (ICDL '99), July 1999, pp. 571-574 SH **EXAMINER DATE CONSIDERED** /Sow Fun Hon/ 06/27/2006

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